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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/612,033	07/03/2003	Tadashi Iguchi	03180.0326	5852
22853 7590 0892725908 FINNEGAN, HENDERSON, FARBOW, GARRETT & DUNNER LLP 901 NEW YORK AVENUE, NW WASHINGTON, DC 20001-4413			EXAMINER	
			QUINTO, KEVIN V	
			ART UNIT	PAPER NUMBER
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

# Application No. Applicant(s) 10/612.033 IGUCHI ET AL. Office Action Summary Examiner Art Unit Kevin Quinto 2826 -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS. WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status 1) Responsive to communication(s) filed on 19 February 2008. 2a) This action is FINAL. 2b) This action is non-final. 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4) Claim(s) 4.7-11.14.16.18.19 and 21 is/are pending in the application. 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration. 5) Claim(s) 4,7-11,14,16,18,19 and 21 is/are allowed. 6) Claim(s) 5.15 and 22 is/are rejected. 7) Claim(s) 17 and 20 is/are objected to. 8) Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement. Application Papers 9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are; a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abevance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some \* c) None of: Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). \* See the attached detailed Office action for a list of the certified copies not received. Attachment(s) 1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413) Paper No(s)/Mail Date. Notice of Draftsperson's Patent Drawing Review (PTO-948) 5) Notice of Informal Patent Application 3) Information Disclosure Statement(s) (PTO/SB/08)

Paper No(s)/Mail Date \_

6) Other:

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#### DETAILED ACTION

#### Response to Arguments

 Applicant's arguments filed February 19, 2008 have been fully considered but they are not persuasive. The applicant argues that Hagiwara (JP 2001-274367) does not disclose a trench in the shape of a U. The examiner would like to point out MPEP 2106 which states that:

USPTO personnel are to give claims their broadest reasonable interpretation in light of the supporting disclosure. In re Morris, 127 Fad 1048, 1054-55, 44 USPO2d 1023, 1027-28 (Fed. Cir. 1997). Limitations appearing in the specification but not recited in the claim should not be read into the claim. E-Pass Techs., Inc. v. 3Com Corp., 343 F. 3d 1384, 1389, 87 USPO2d 1947, 1950 (Fed. Cir. 2003) (claims must be interpreted "in view of the specification" without importing limitations from the specification into the claims unnecessarily). In re Prater, 415 F.2d 1393, 1404-05, 162 USPO2 650-051 (CPO4 1999). See also in re Zletz, 893 F.2d 319, 321-22, 13 USPO2d 1320, 1322 (Fed. Cir. 1989) ("During patent examination the pending claims must be interpreted as broadly as their terms reasonably allow.... The reason is simply that during patent prosecution when claims can be amended, ambiguities should be recognized, scope and breadth of language explored, and clarification imposed.... An essential purpose of patent examination is to fashion claims that are precise, clear, correct, and unambiguous. Only this way can uncertainties of claim scope be removed, as much as possible, during the administrate process.").

The examiner believes that the claim 5 limitation, "being in the shape of U" is met by Hagiwara in its broadest reasonable interpretation. Therefore the rejection of claims 5, 15, and 22 under 35 U.S.C. 102(b) as being anticipated by Hagiwara (JP 2001-274367) stands.

2. The applicant traverses the objection of claims 17 and 20 made in the previous Office action and argues that the claim language is consistent with the specification. As the applicant pointed out in the response filed on February 19, 2008, the specification, on p. 17, lines 20-21, discloses (emphasis added), "forming side wall spacers 59S on sides of the floating gate electrodes 5." This language is not consistent with the language of claim 17 which states. "making a side wall spacer on a surface of each of

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said isolating fillers in a side wall of said floating gate electrodes." Therefore the objection stands.

# Claim Objections

3. Claims 17 and 20 are objected to because of the following informalities: the phrase "making a side wall spacer on a surface of each of said isolating fillers in a side wall of said floating gate electrodes" in claim 17 is incorrect since the spacer is not in the sidewall of the floating gate. Appropriate correction is required.

#### Claim Rejections - 35 USC § 102

4. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States
- Claims 5, 15, and 22 are rejected under 35 U.S.C. 102(b) as being anticipated by Hagiwara (JP 2001-274367).
- 6. In reference to claim 5, Hagiwara (JP 2001-274367) discloses a structure which meets the claim. Figure 29 of Hagiwara discloses a semiconductor memory comprising a memory cell array constituted by memory cells with each memory cell having a floating electrode (140). The memory cells are arranged in a matrix on a semiconductor substrate (100). A plurality of first trenches is formed in the semiconductor substrate (100). Each first trench is formed between adjacent ones of said memory cells along a

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gate width direction. A plurality of isolating fillers (110) is filled in the first trenches. A plurality of second trenches is formed in the isolating fillers (110). Each second trench is formed between the floating electrodes (140) of adjacent ones of the memory cells along the gate width direction. The second trenches are in the shape of a U. A word line (160) is connected to the memory cells and is buried in the second trenches and extending along the gate width direction.

- 7. With regard to claim 22, the applicant has characterized a second trench which is capable of reducing parasitic capacitance as being shallower than the first trench and preferably reaches at least the surface of the well region (currently filed specification, p. 9, lines 16-21). The second trench of Hagiwara meets these characteristics thus meeting the claim. Furthermore, the applicant has characterized a second trench as reducing parasitic capacitance since the parasitic capacitance generated by the floating gate, the dielectric in the trench, and an insulating film of the trench, and at the word line is electrically connected in parallel to the parasitic capacitance between floating gates of the memory cells (currently filed specification, p. 3, lines 6-16). The second trench of Hagiwara also meets these characteristics as well and thereby meets the claim.
- 8. With regard to claim 15, Hagiwara (JP 2001-274367) discloses a method which meets the claim. Figure 29 of Hagiwara discloses a method of manufacturing a semiconductor memory which comprises making element isolating regions (110) by forming a plurality of first trenches in a semiconductor substrate (100). Each first trench is made between adjacent ones of a plurality of memory cell forming regions along a gate width direction. The plurality of first trenches is filled with a plurality of isolating

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fillers. A plurality of floating gate electrodes (140) is formed on the semiconductor substrate (100) at the memory cell forming regions. The floating gate electrodes (140) have a predetermined gate width. A plurality of second trenches is formed in the isolating fillers filled in the first trenches. Each second trench is made between adjacent ones of the floating electrodes (140) along the gate width direction. The second trenches are made in the shape of a U. A word line (160) is formed in the second trenches. The word line (160) extends along the gate width direction.

## Allowable Subject Matter

- 9. Claims 4, 7-11, 14, 16, 18, 19 and 21 were allowed in the previous Office action.
- 10. The following is an examiner's statement of reasons for allowance: the reasons for allowance were cited in the previous Office action.

# Conclusion

 THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

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the advisory action. In no event, however, will the statutory period for reply expire later

than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Kevin Quinto whose telephone number is (571) 272-

1920. The examiner can normally be reached on M-F 8AM-5PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Sue Purvis can be reached on (571) 272-1236. The fax phone number for

the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the

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/Kevin Quinto/

Examiner, Art Unit 2826

/A. Sefer/
Primary Examiner
Art Unit 2826